



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. .... 10/655,997  
Filing Date ..... September 5, 2003  
Confirmation No. .... 7524  
Inventor ..... Jon P. Daley  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2822  
Examiner ..... Pamela E. Perkins  
Attorney's Docket No. .... MI22-2380  
Customer No. .... 021567  
Title: Methods of Forming Patterned Photoresist Layers Over Semiconductor  
Substrates

### RESPONSE TO AUGUST 8, 2005 FINAL OFFICE ACTION PRELIMINARY AMENDMENT TO ACCOMPANY RCE FILING

To: Mail Stop RCE  
Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450 VIA U.S. EXPRESS MAIL

From: Mark S. Matkin (Tel. 509-624-4276; Fax 509-838-3424)  
Wells St. John P.S.  
601 West First Avenue, Suite 1300  
Spokane, WA 99201-3828

Responsive to the Final Office Action dated August 8, 2005, Applicant  
amends and remarks as follows:

### AMENDMENTS

12/05/2005 DEMMANU1 00000109 10655997

01 FC:1201 400.00 OP  
02 FC:1202 200.00 OP